

**Electronic Filing System (EFS) Data
Electronic Patent Application Submission
USPTO Use Only**

EFS ID: 60295
Application ID: 10709406 
Title of Invention: METHOD TO REDUCE
PHOTORESIST PATTERN
COLLAPSE BY CONTROLLED
SURFACE MICROROUGHENING
First Named Inventor: Colin Brodsky
Domestic/Foreign Application: Domestic Application
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U.S. DEPARTMENT OF COMMERCE
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FEE RECORD SHEET

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